

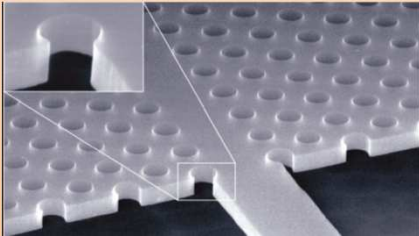
INDIA NANO 2019

Workshop on
Nanolithography and Nanofabrication

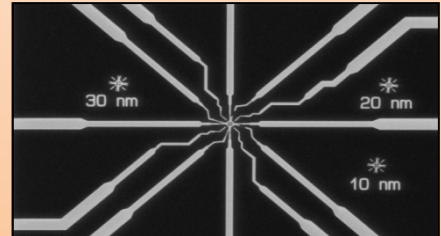
organized by
RAITH INDIA, Bangalore
in cooperation with
S.N. Bose National Centre for Basic Sciences, Kolkata
on
Tuesday, 9 July 2019

Followed by the India Raith User Meeting on Wednesday, 10 July 2019

at
S.N. Bose National Centre for Basic Sciences JD Block, Sector III
Salt Lake City, Kolkata - 106



Register now!
Seats are limited



The aim of the workshop is to provide a broad overview on **Electron and Ion beam patterning** techniques and related processes which are fundamental for nanofabrication in R&D and **small scale production**. Earlier, workshops were organized at IITB Mumbai in 2009, CeNSE, IISc Bangalore in 2012, NRF, IITDelhi in 2015 and CeNSE, IISc Bangalore in 2017.

• **This workshop includes:**

- Speakers from Raith
 - EBL – IBL – Metrology
 - SEM (FIB) nano-patterning attachments
- Speakers from Oxford Instruments
 - RIE - Deposition
- Speakers from Indian Institutes
 - Interesting applications from Raith users

• **Salient features of workshop:**

- No registration fee is charged
- Snacks, Tea, Coffee, Lunch and Dinner (for day 1) is included
- Accommodation and transport has to be taken care by participants
- Interested researchers and students are invited to register. **Kindly email your name, Institute, address & contact number to masum.khan@raithindia.com before July 3, 2019.**

This workshop is useful for:

- ✓ Scientists who plan to have a Nano lithography/fabrication facility in future
- ✓ The User Meeting (only for existing Raith system users) to exchange knowledge
- ✓ Participants will have throughout opportunities to network with scientists already working in this exciting research area

For further details, please contact:

- Mr. Masum Khan, Raith India Email: masum.khan@raithindia.com Mobile: 9902991786
- Dr. Atindra Nath Pal, SNBNCBS Email: atin@bose.res.in Mobile: 7319044924